

New semiconductor 2D position-sensitive detector

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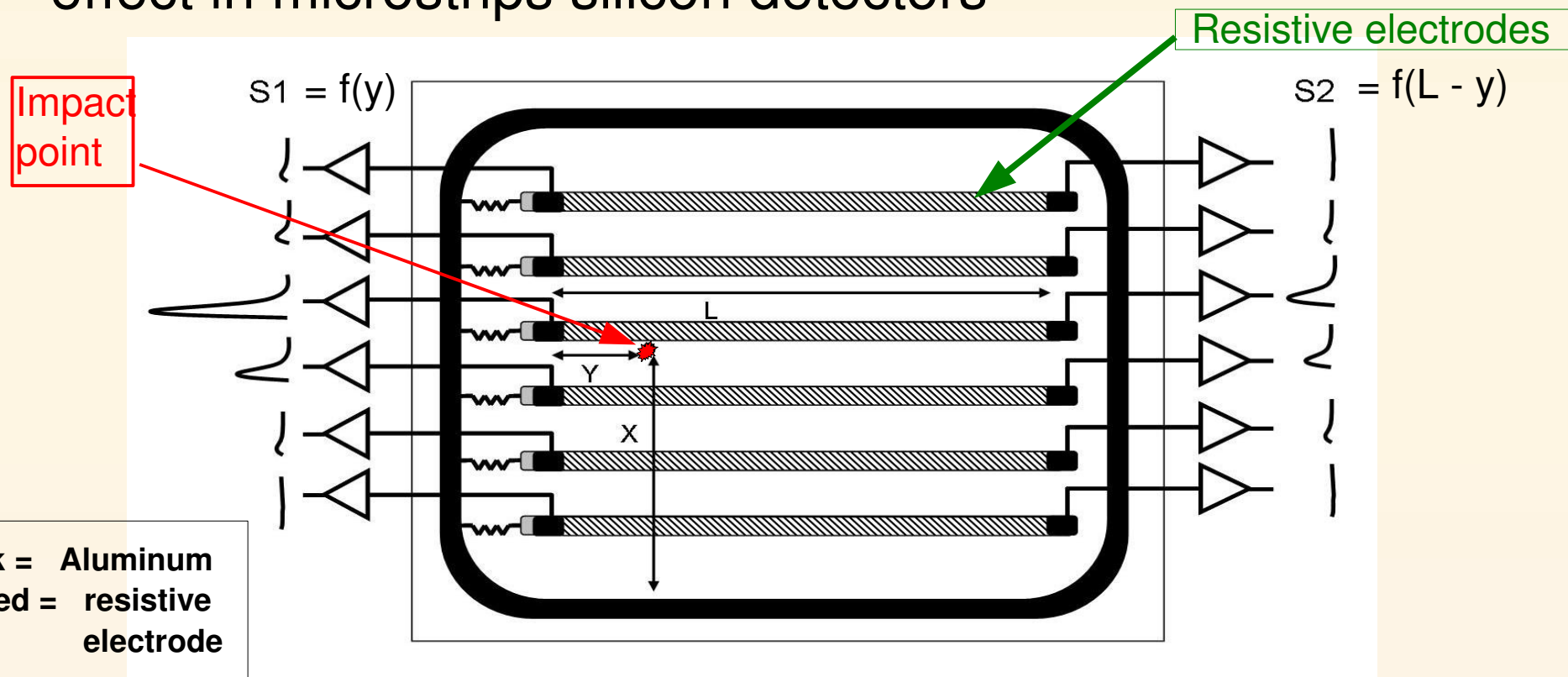


Outline:

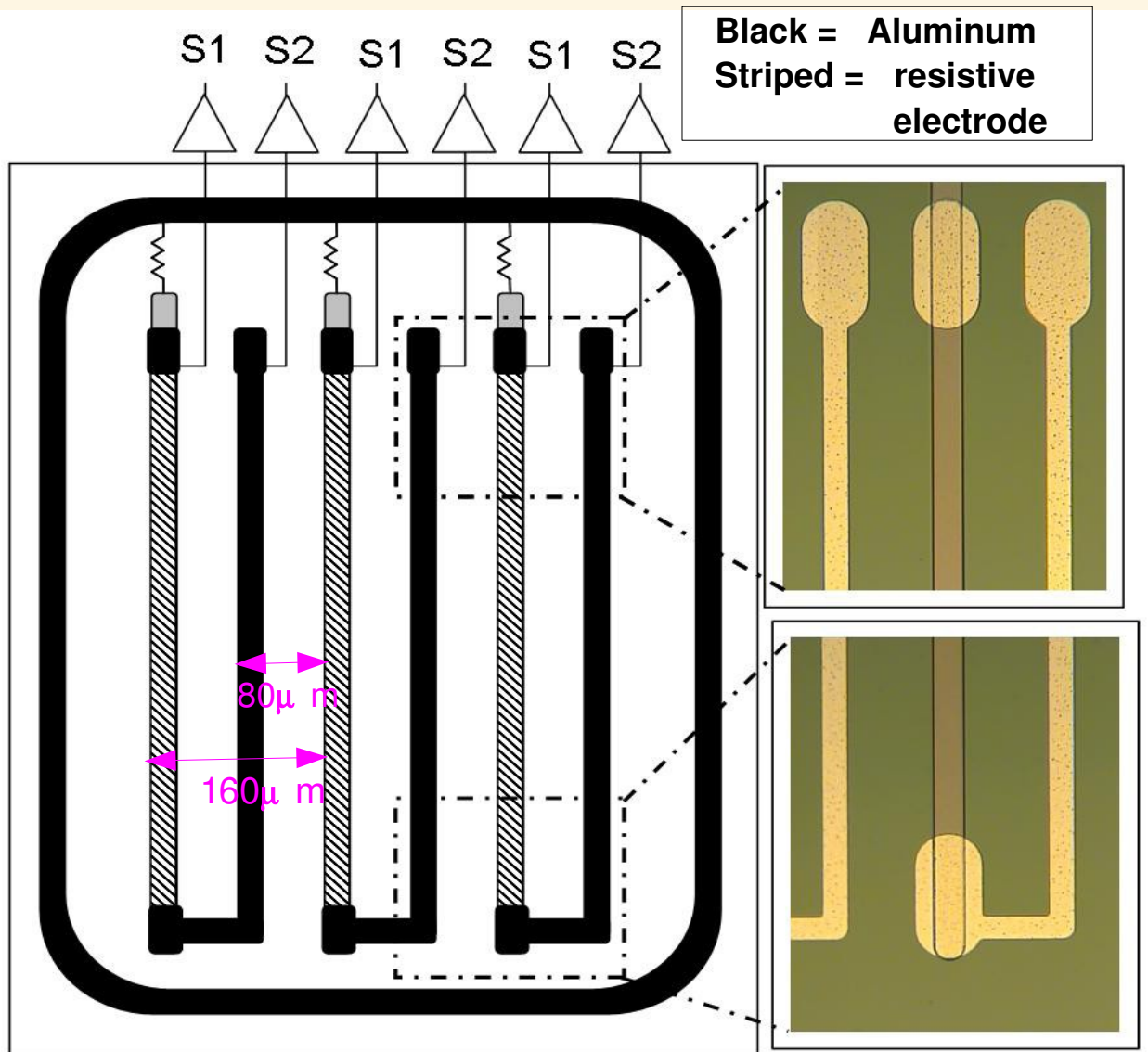
Recalling the charge division principle
Description “proof of concept” prototypes
Laser and ^{90}Sr source characterization
Results from test beam @ SPS (CERN)
Few words about second Prototype
Next steps & Conclusions

Charge division principle

- Charge division in wire chambers is used to determine the coordinate along the sensing wire
- Electrodes with slightly resistive material produce same effect in microstrips silicon detectors



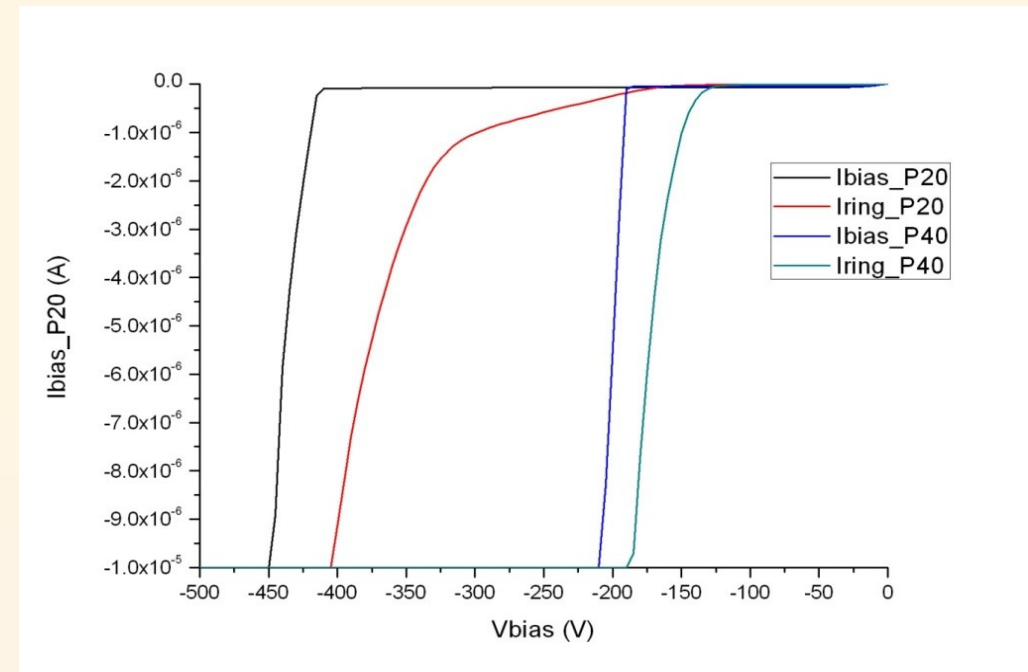
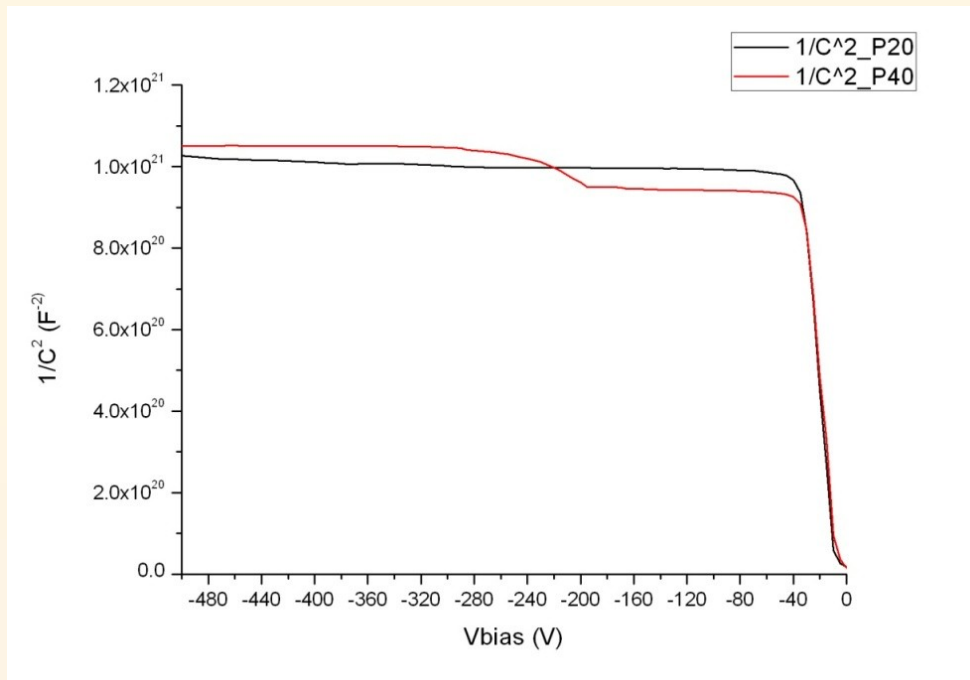
First prototype and main characteristics



- * The **first prototypes** of the new sensors have been designed and produced at the **IMB-CNM** facilities
- * Standard planar **technology** p-on-n, 300 μ m thick
- * Highly doped **polysilicon** as resistive electrode
- * Strip length = 14 mm
- * 68 strips/detector
- * 2 prototypes with different strip widths: (20,40) μm
- * Aluminum via to drive the contact pads at the same edge of the detector. **Only 1 chip to readout the detector!!!**

Electrical characterization

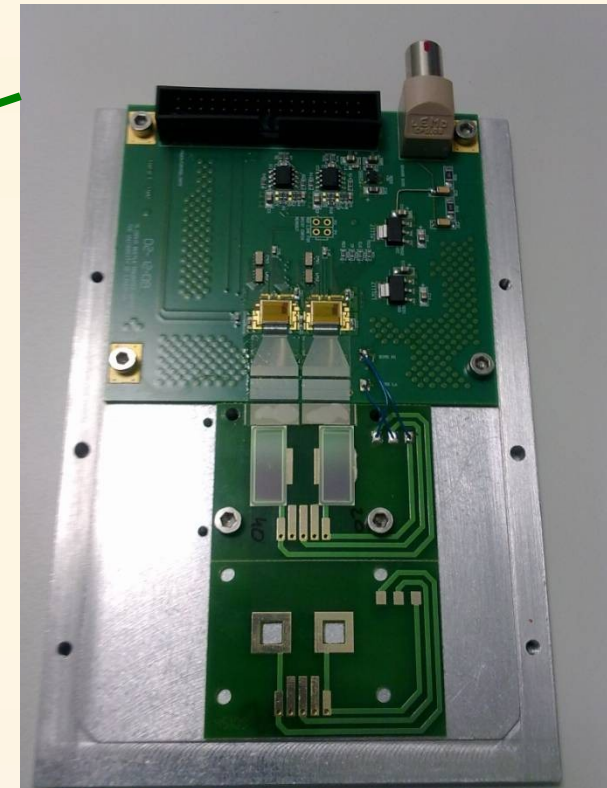
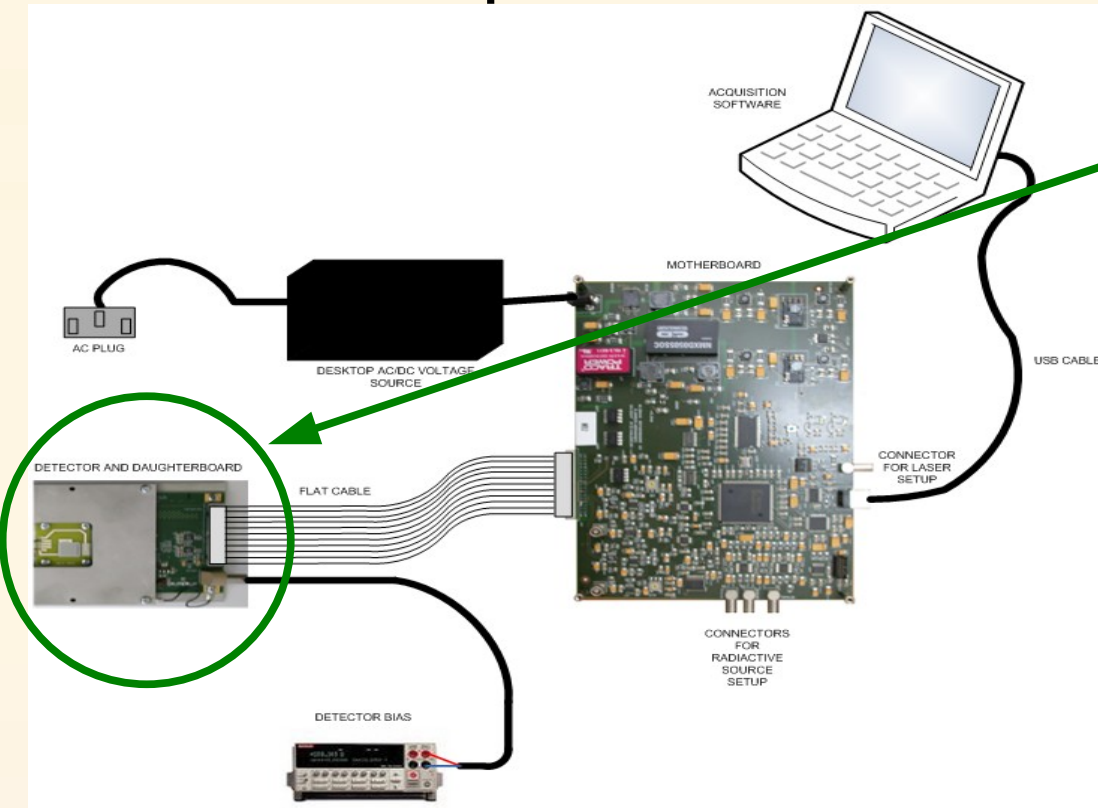
Strip Width	V_{depl}	V_{tot}	R_{bias}	R_{irt}	C_{irt}	C_{cap}	$R_{\text{electrode}} / \square$	$R_{\text{electrode}} / \mu\text{m}$
20 μm	40 V	> 400 V	1,31 M Ω	> G Ω	1,32 pF	248 pF	400 Ω/\square	20 $\Omega/\mu\text{m}$
40 μm	40 V	> 200V	1,37 M Ω	> G Ω	1, 60 pF	487 pF	400 Ω/\square	10 $\Omega/\mu\text{m}$



Readout electronic: ALIBAVA

Portable system
Beetle chip

Daughter board &
detectors

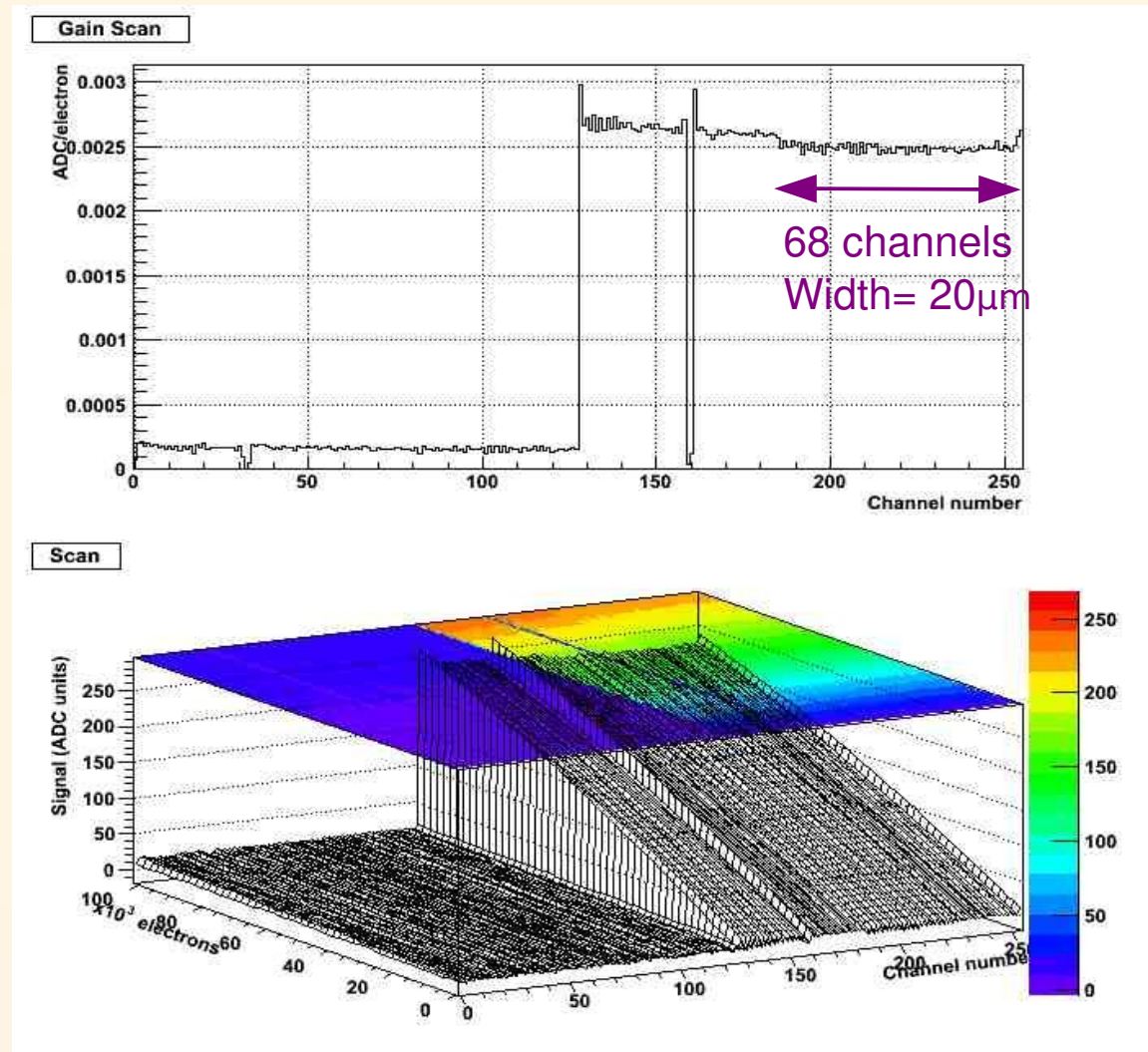


Chips calibration

* *Chip1* Did not perform the calibration

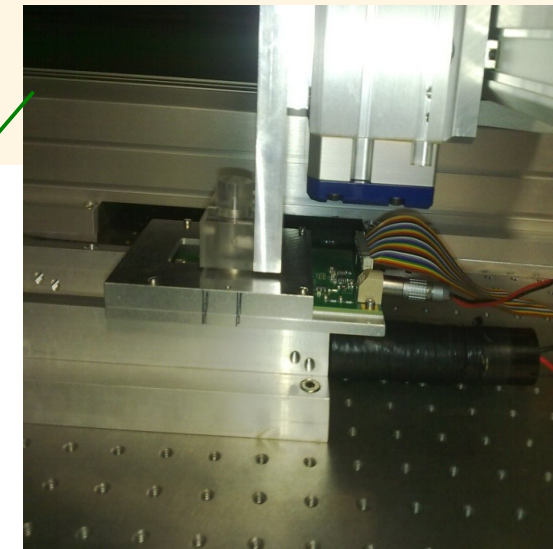
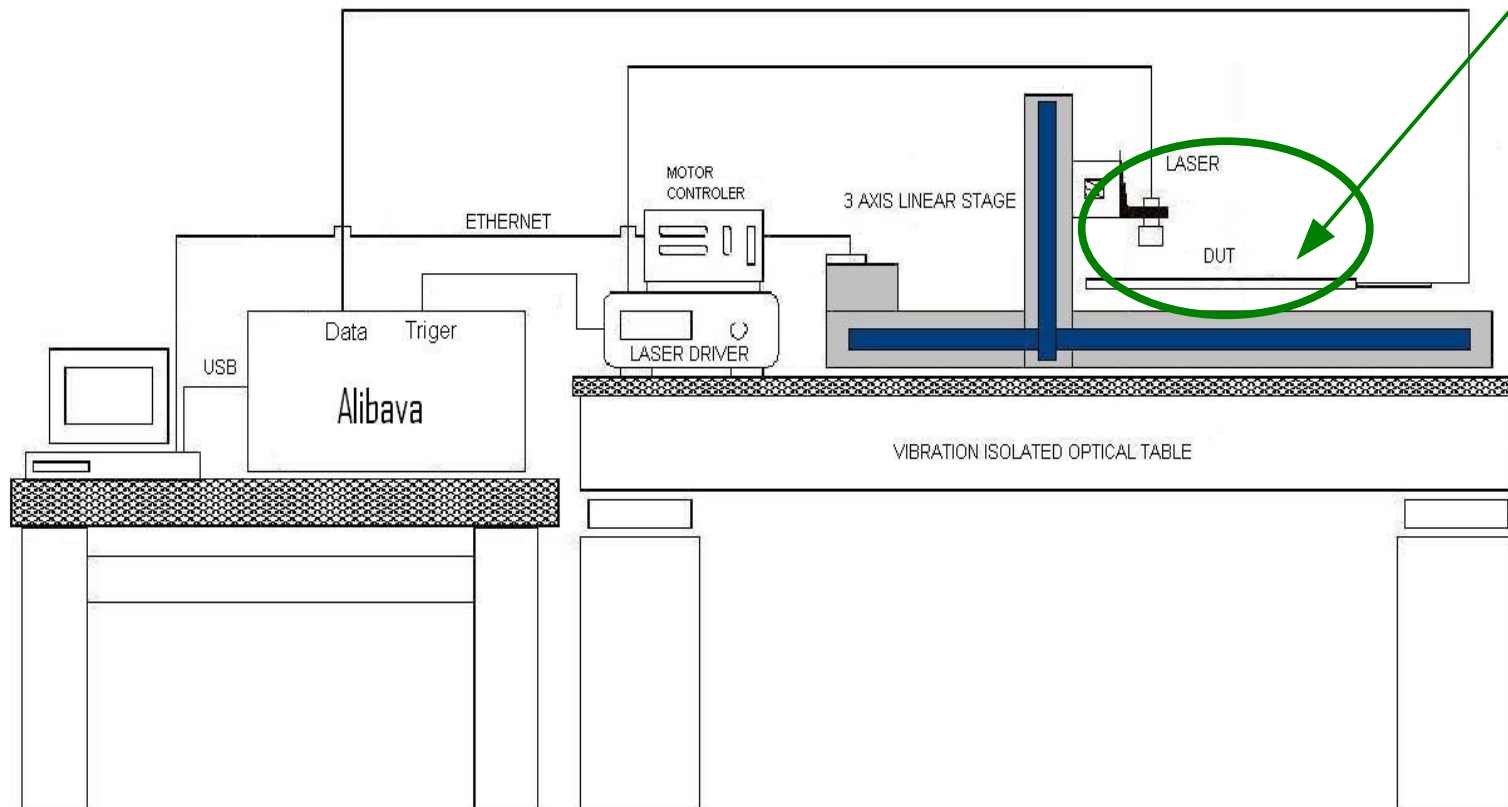
* No data for detector with a width of $40\mu\text{m}$

* Linearity on the response



Laser characterization. Test stand

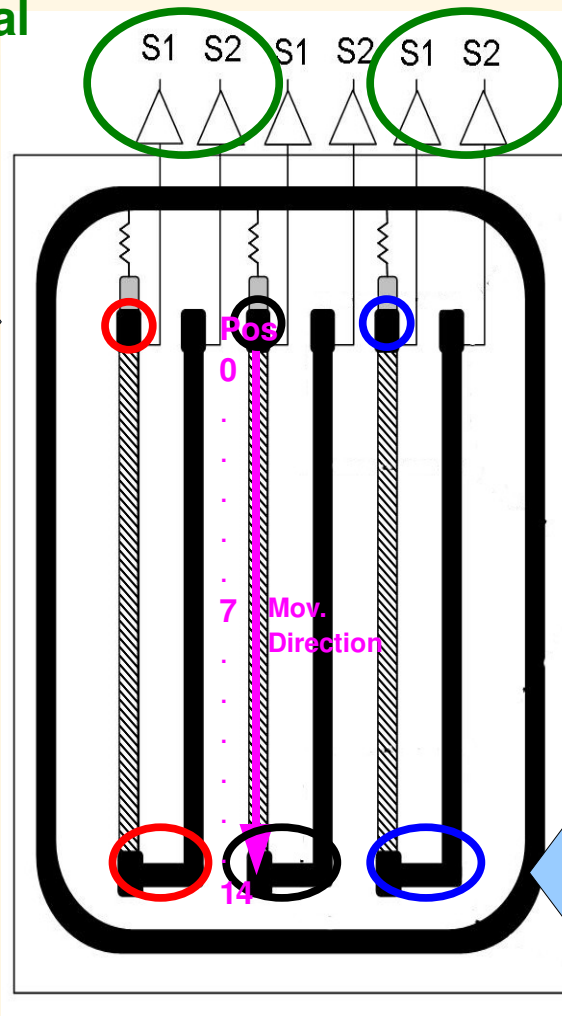
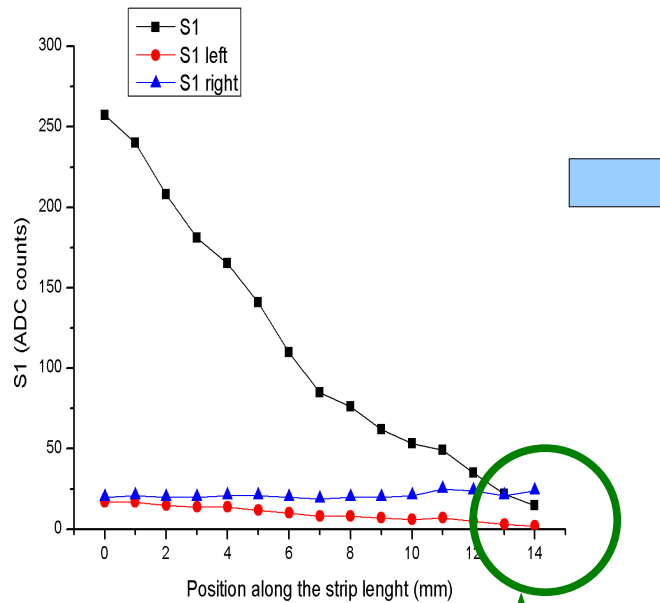
- * 3D stage platform. $\sim 5\mu\text{m}$ accuracy
- * $\lambda = 1080\text{ nm}$
- * Gaussian profile. Microspot width $2\sigma < 10\ \mu\text{m}$
- * Pulse duration $< 1\text{ ns}$
- * Pulse energy $\sim 10\%$ gaussian fluctuation



Laser longitudinal scan

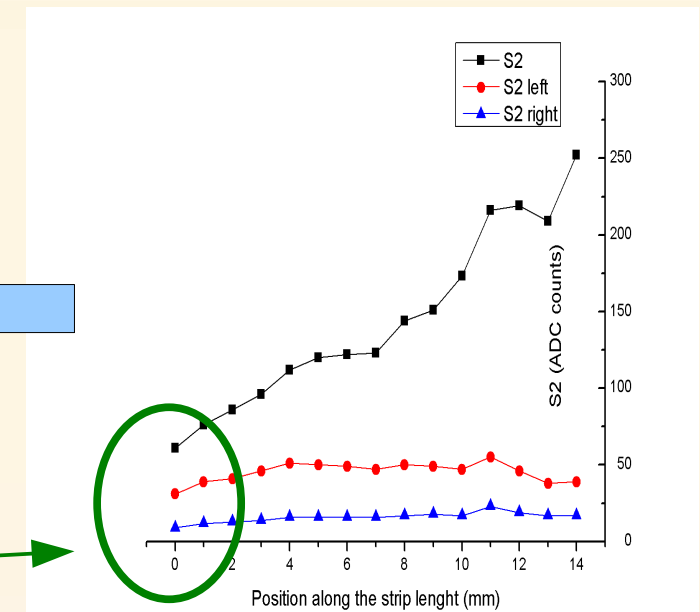
Left signal

Right signal



Are not perfectly antisymmetric!

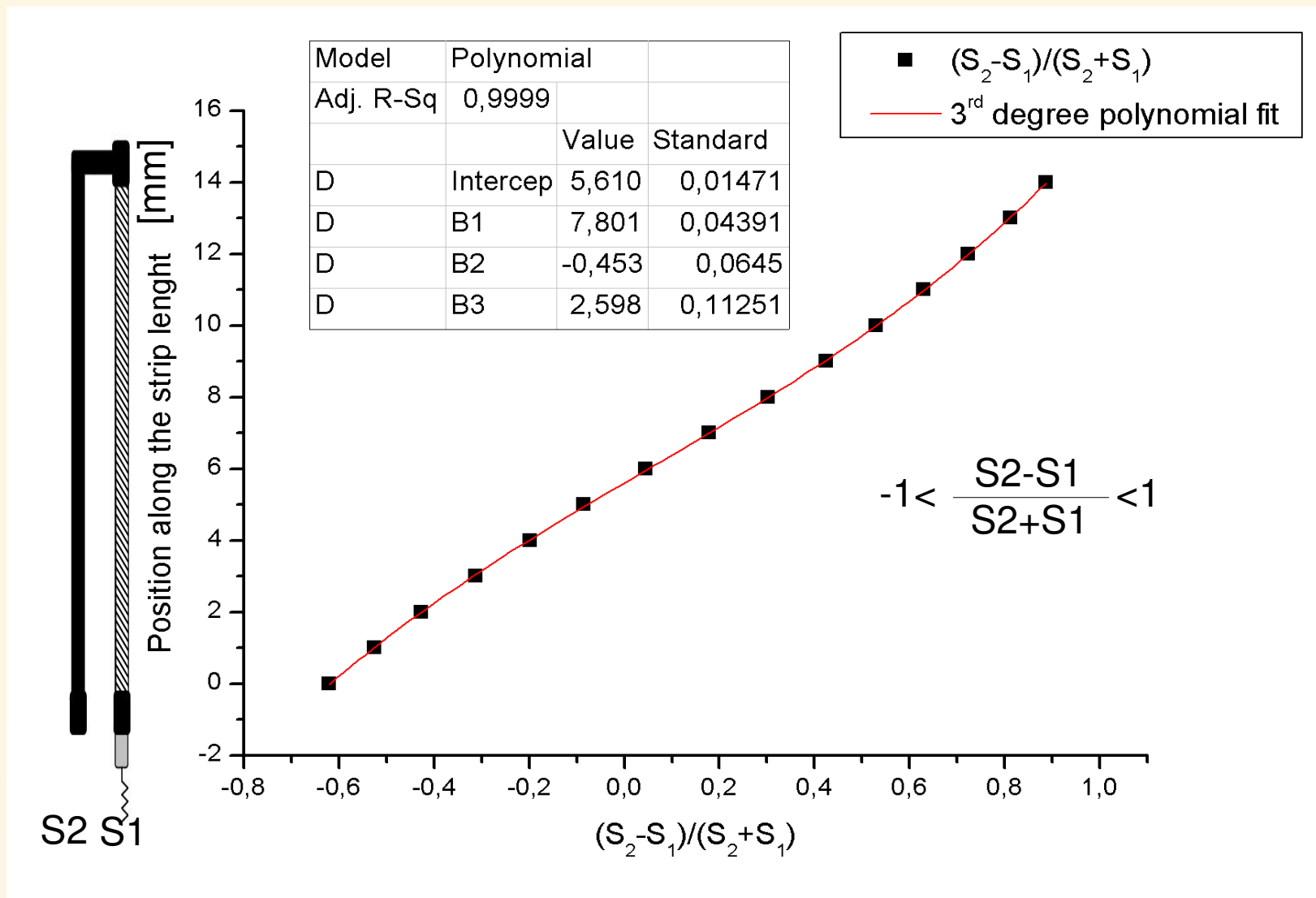
Coupling effect?



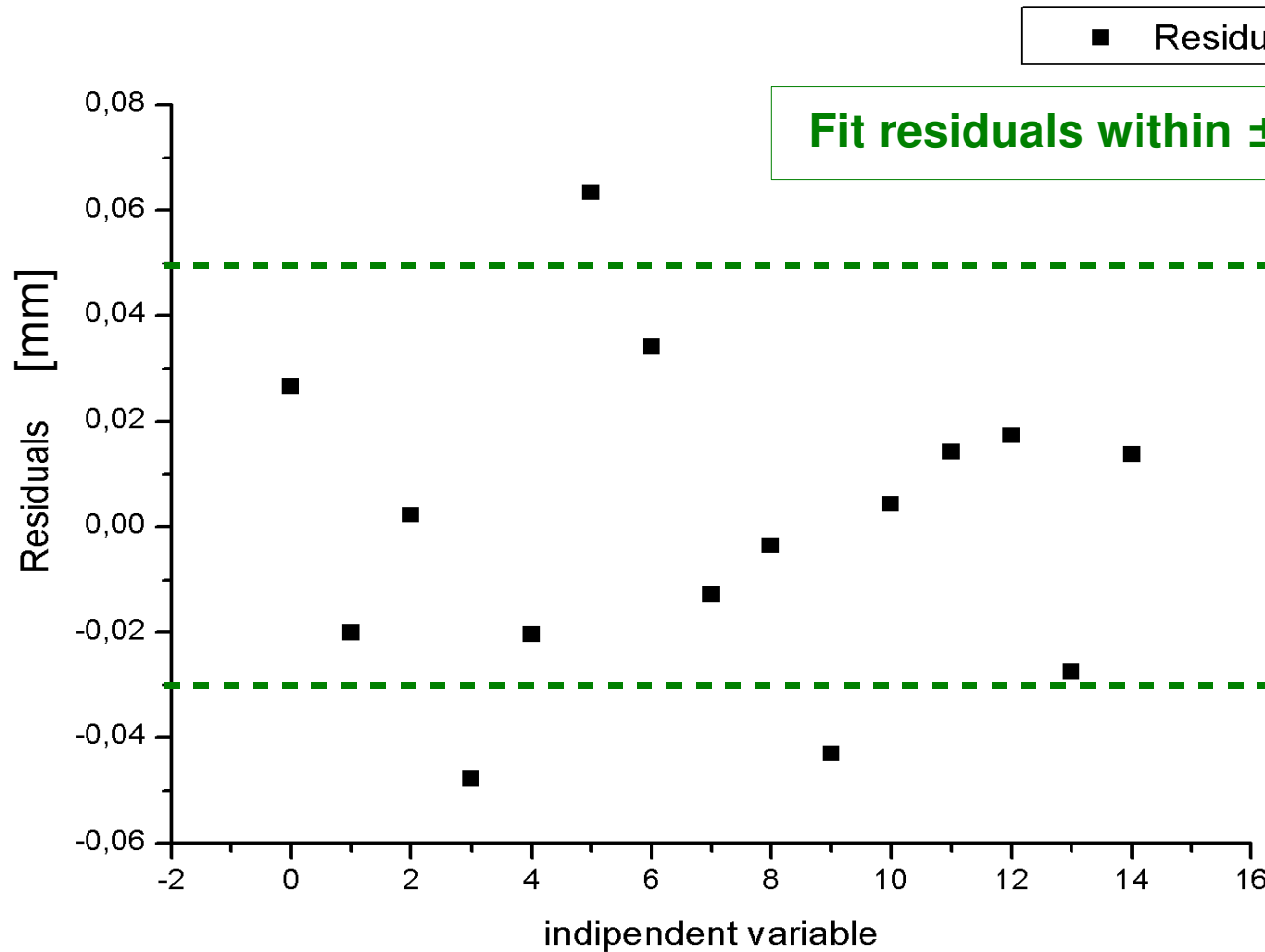
At position 0: $S2 \neq 0$



Charge division. experimental results



Charge division. experimental results



With this detector, the coordinate along the strip can be determined in a range of $100 \mu\text{m}$

S2

S1

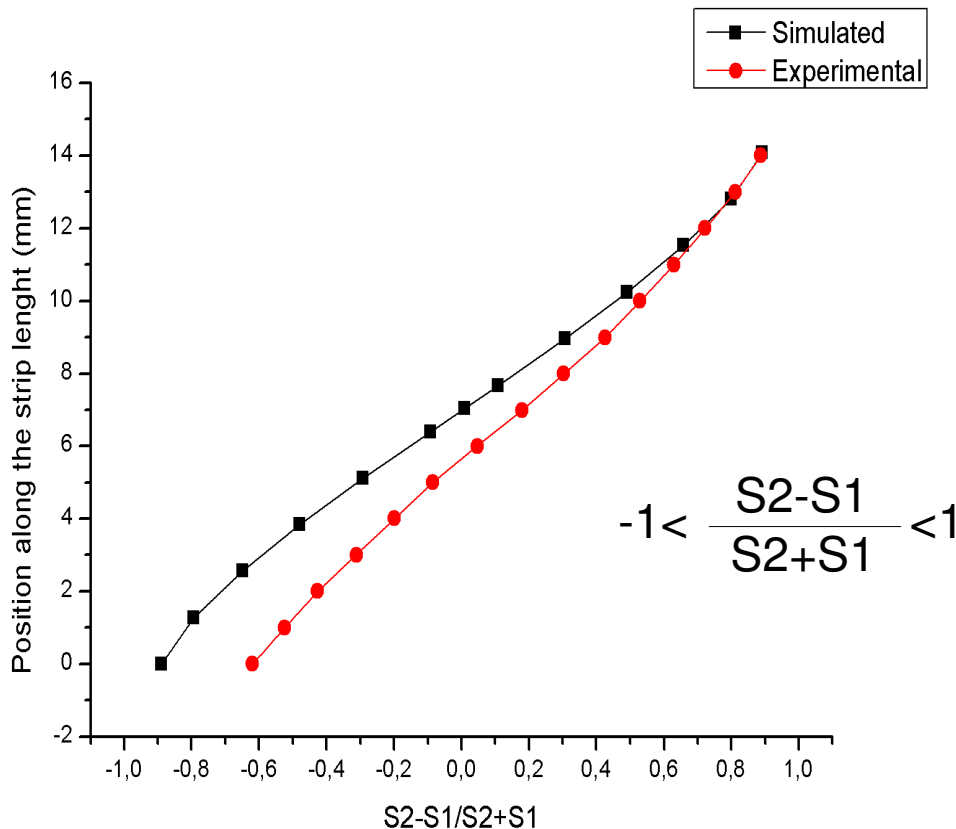
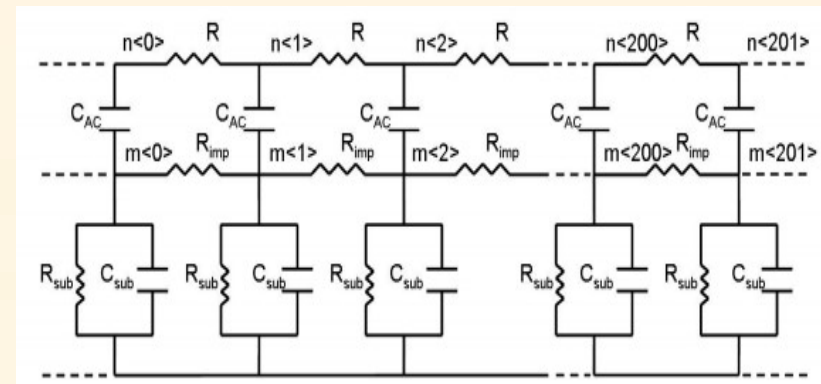


Simulation & data comparison

* Circuital model: (N, Bachetta et al., IEEE, Vol 47, NO 4, August 1995)

Five strips (R_{str} , C_{cou} , R_{met}). Interstrip circuital elements (C_{int} , R_{int} , C_m , C_p).

Bulk representation (R_{sub} , C_{sub})

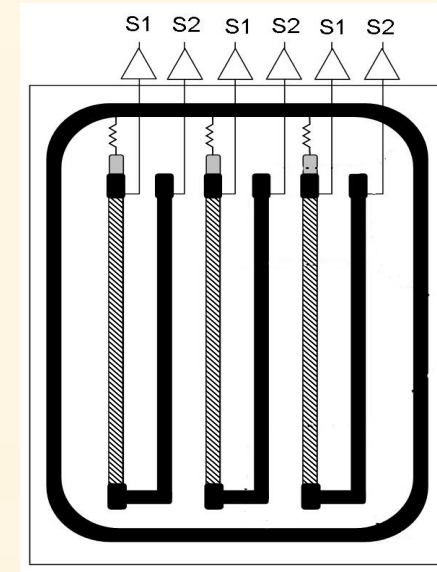
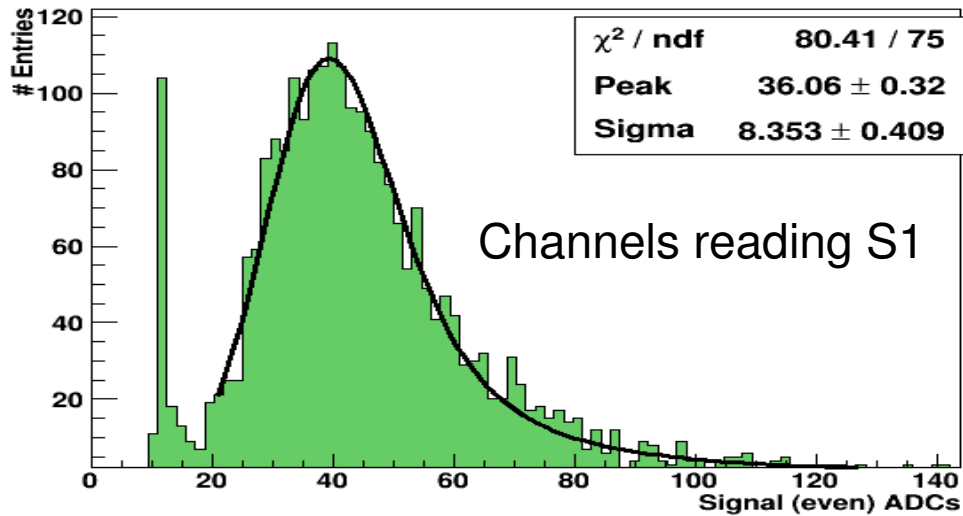


* Overall shape reproduced

* Signal excess in S2, caused for coupling between resistive electrode and metal wire

Radio source characterization.

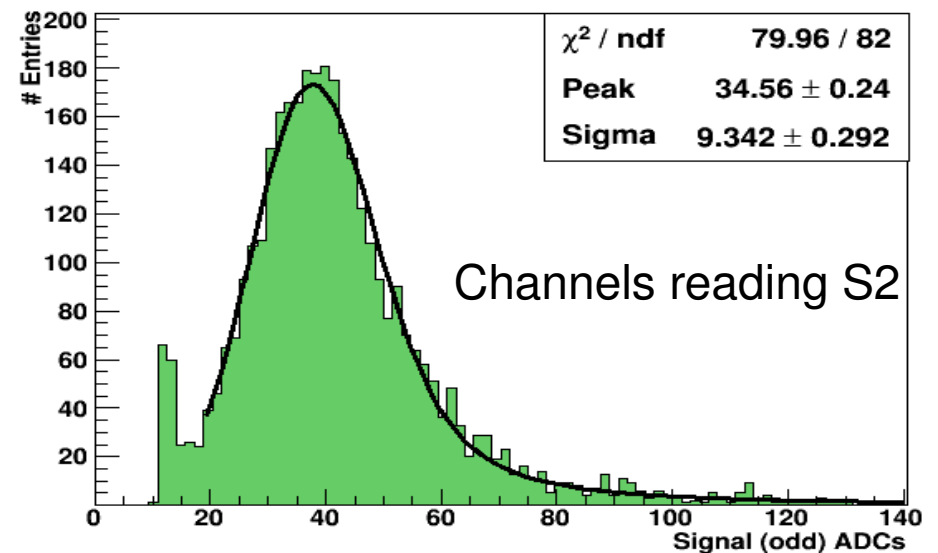
Spectrum with Time cut [1 , 22]



Averaged noise Chip 2 = 2.18 ADCs

SNR ~ 15

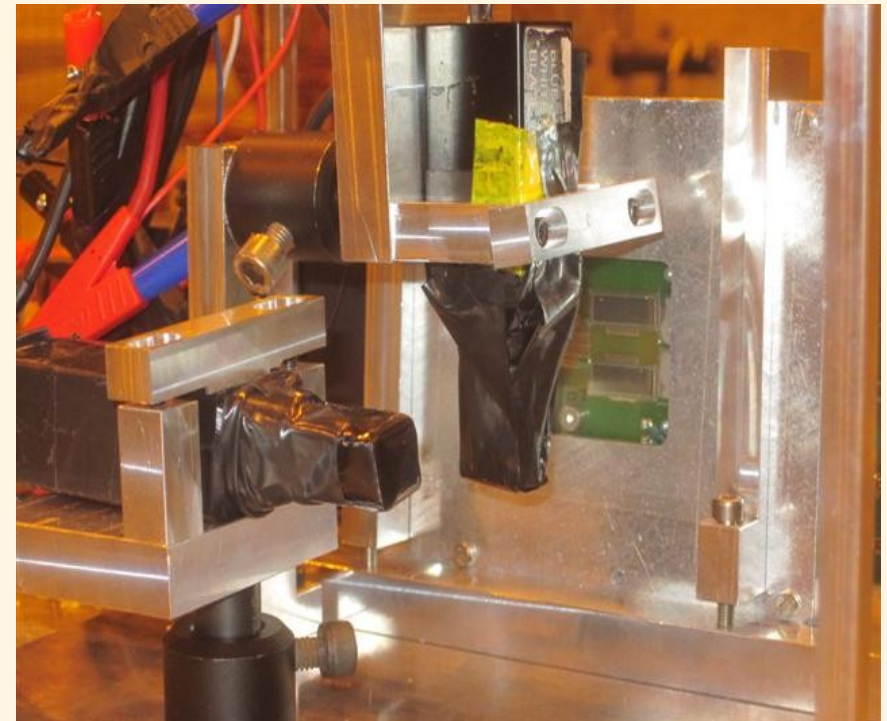
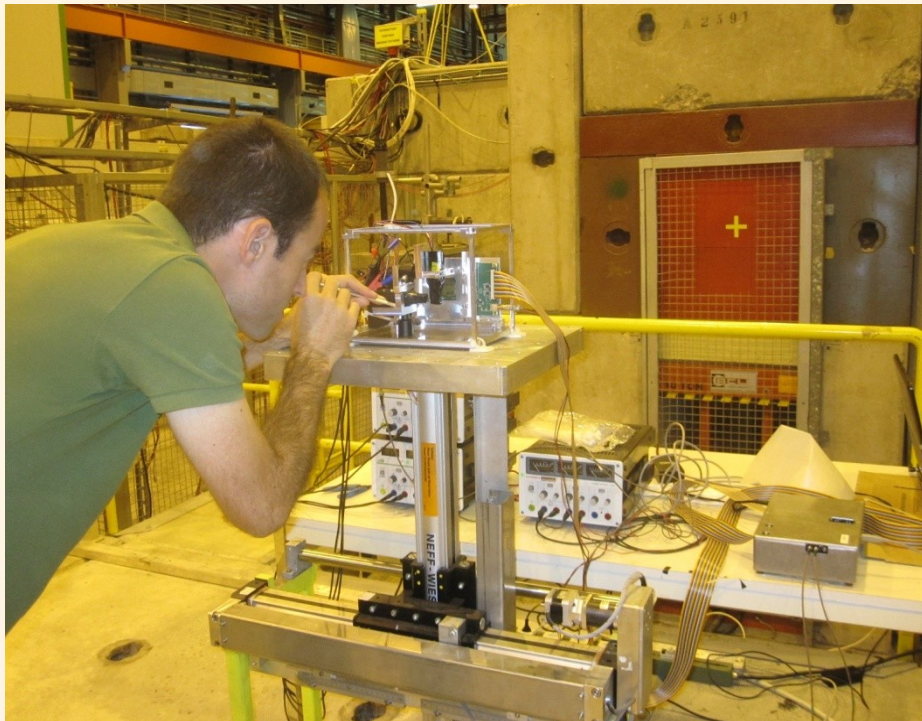
Spectrum with Time cut [1 , 22]



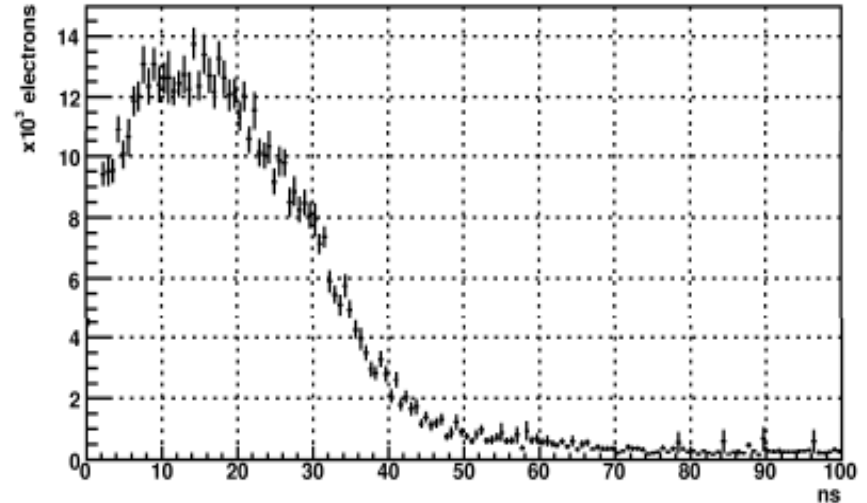
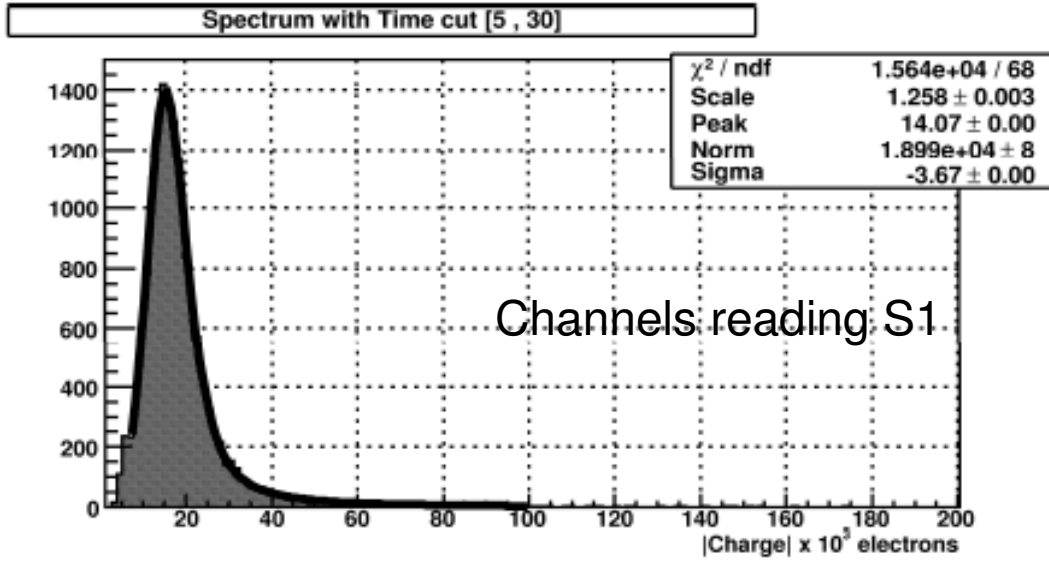
Test beam @ SPS

During the first week of October testing at SPS pion (120GeV) beam in parasitic mode

Alibava DAQ (LHCb beetle chip)

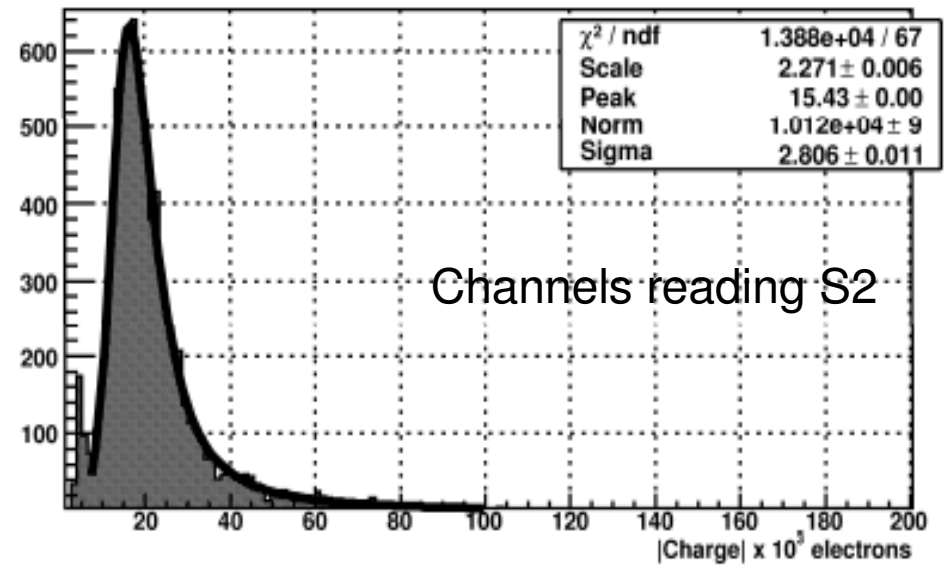
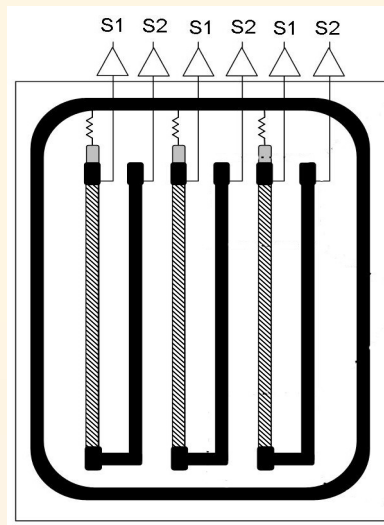


Test beam data



Noise:
Chip 2 = 900 ENC

SNR ~ 15



Test beam @ SPS

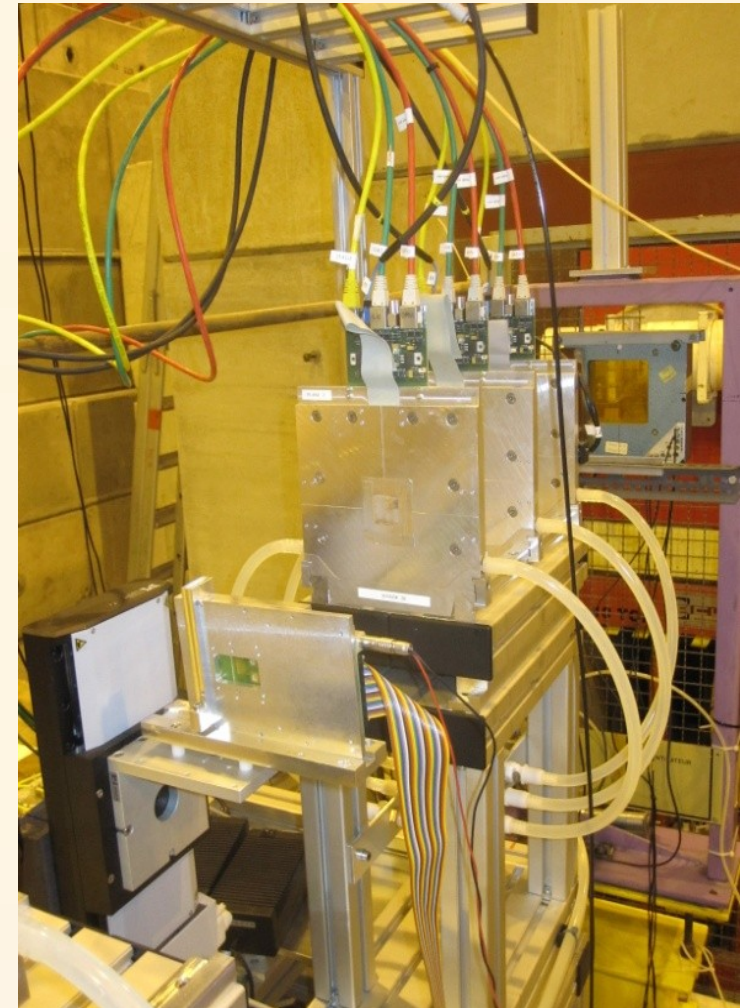
Inside EUDET mimosa telescope

- * APV25 DAQ system
- * T. Bergauer et al.

HEPHY institute (Vienna)

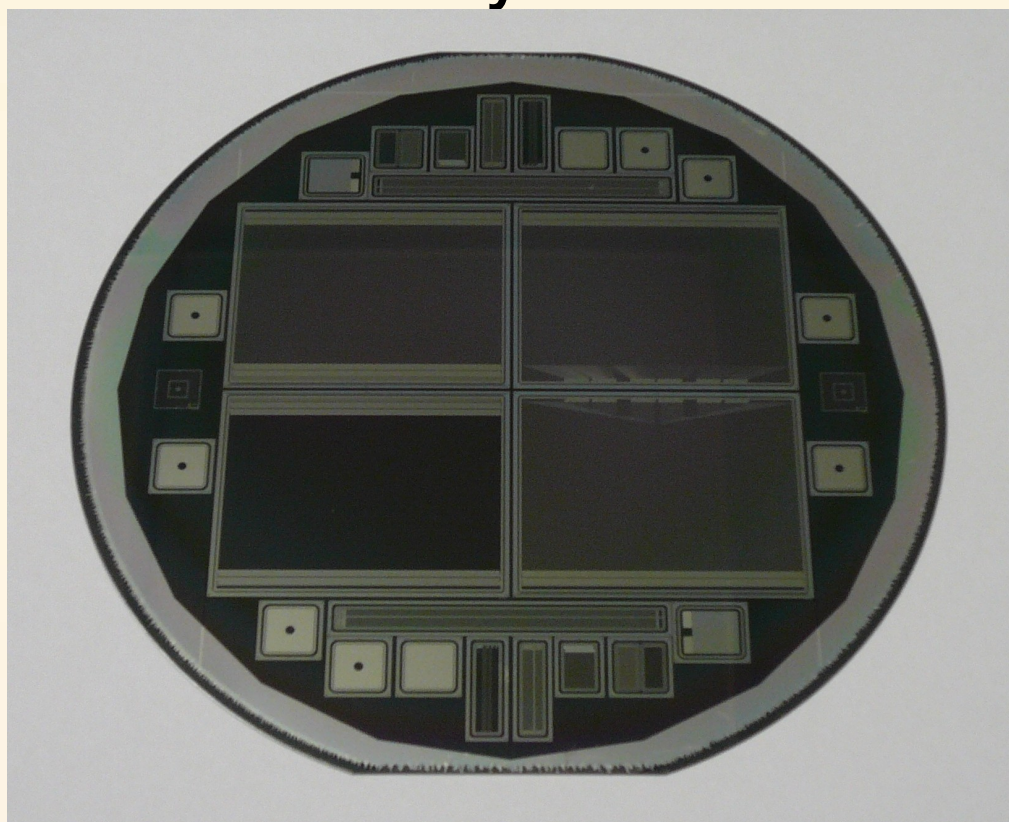


- * Analyzing data with telescope tracker



Second prototype

- * New 2D strip sensor of large area produced at CNM (3 cm strip length). 6 Wafers.
- * Electrically characterized



- * Different electrical test structures
- * Standard strip detector
- * 2 fanout integrated sensors

Second prototype & Some electrical Characteristics

- * No - Aluminum via. Contacts at both strip ends to be read out by two independent FE chips
- * New Sensor board produced at CNM adapted to ALIBAVA

$V_{fd} \sim 40 \text{ V}$

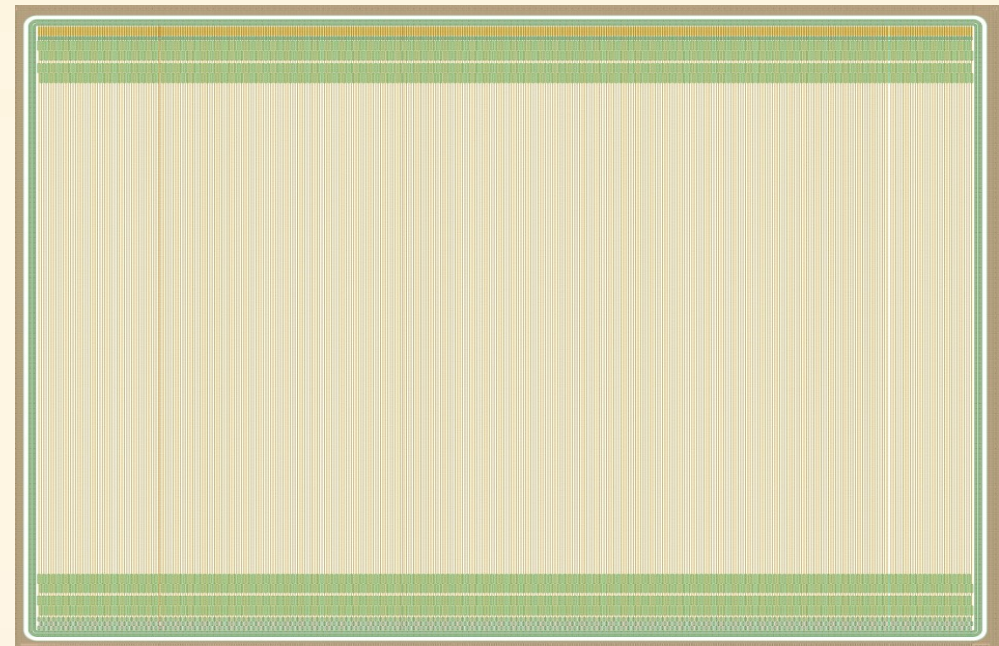
$C_{int} \sim 0.4 \text{ pF}$

$R_{int} > \text{G}\Omega$

$R_{bias} = 2.5 \text{ M}\Omega$

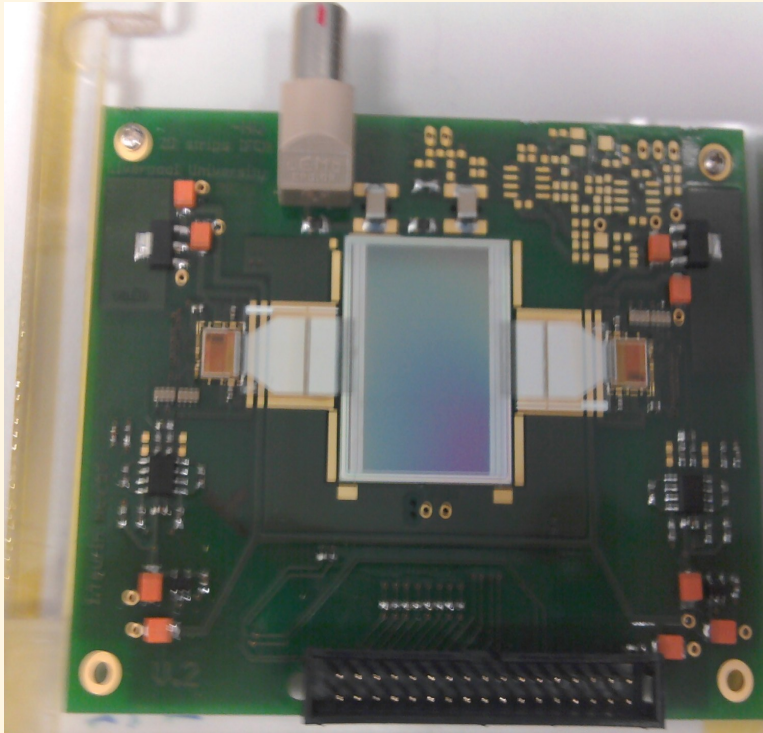
2 wafers $R_{electr.} = 90 \text{ }\Omega/\text{sqr}$

4 wafers $R_{electr.} = 380 \text{ }\Omega/\text{sqr}$



Short term plans

- * 2 New prototypes already bonded. 128 channels each



Bonding done at:
UNIVERSITY of LIVERPOOL



UNIVERSITY OF
LIVERPOOL

- * Preparing setup to be tested with laser and radioactive source
- * Next test beam at SPS on August 2011

Conclusions



- * We have demonstrated the feasibility of the charge division method in microstrip sensors to determine the coordinate along the strip
- * Resolution in the determination of the strip coordinate much better than 100 μm
- * We have used the standard (cheap) technology to produce this genuine 2D single sided strip detector

Possible application targets:

Future detector outer trackers (trigger capable modules)

Ions tracking systems.

Neutron imaging (+ conversion element).

Space applications.



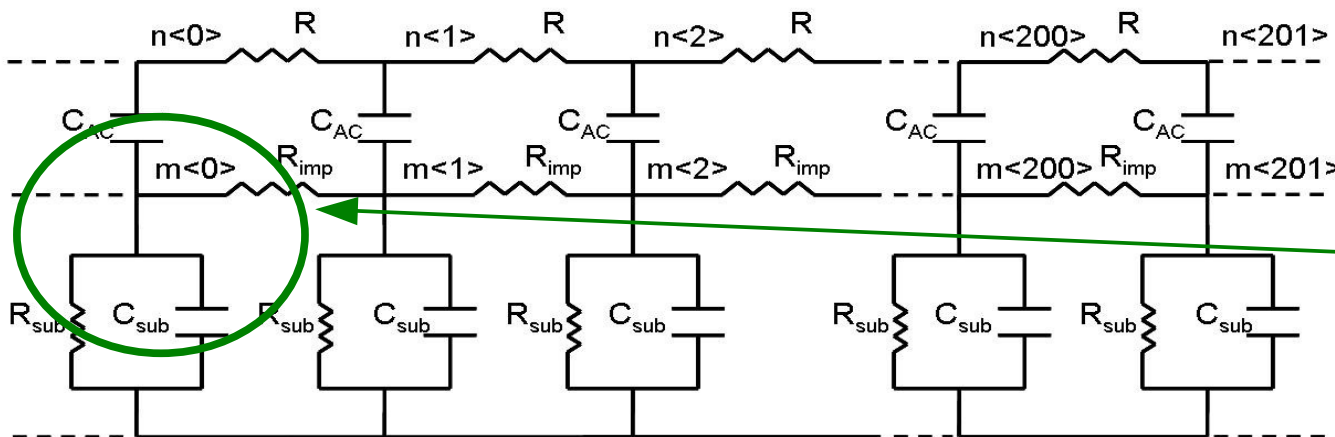
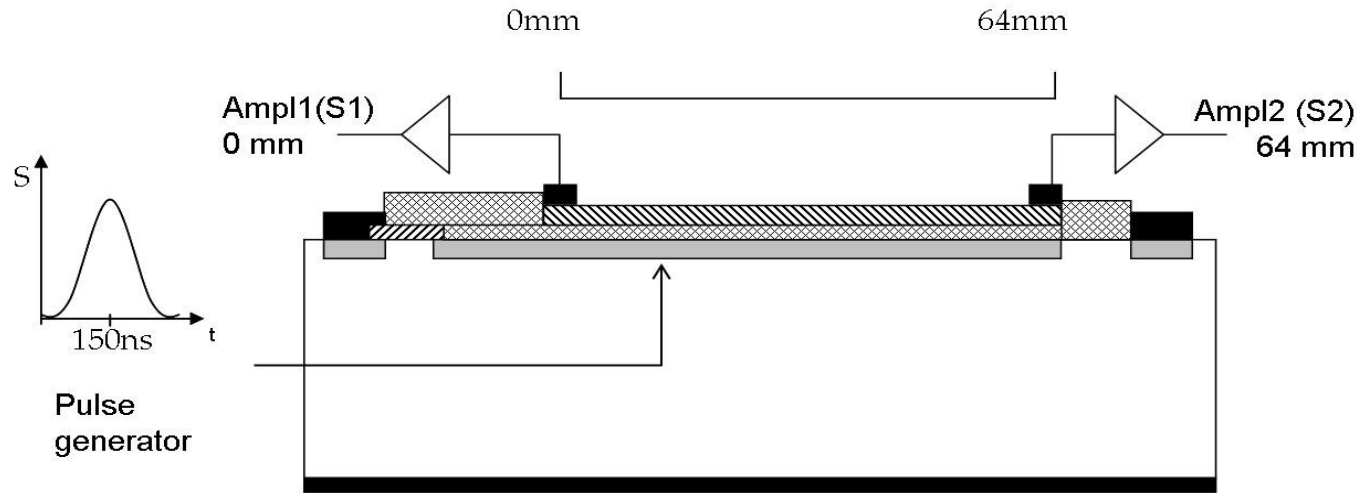
THANKS FOR YOUR ATTENTION!

BACKUP

SPICE model

D. Bassignana (CNM-Barcelona)

■ = Al ▨ = R_{bias} ▩ = SiO_2 ▧ = Resistive material ◻ = p^+ implants



Circuital model:

(N, Bachetta et al., IEEE, Vol 47, NO 4, August 1995)

n = node number

m = pulse impact

R = electrode resistance

R_{imp} = implant resistance

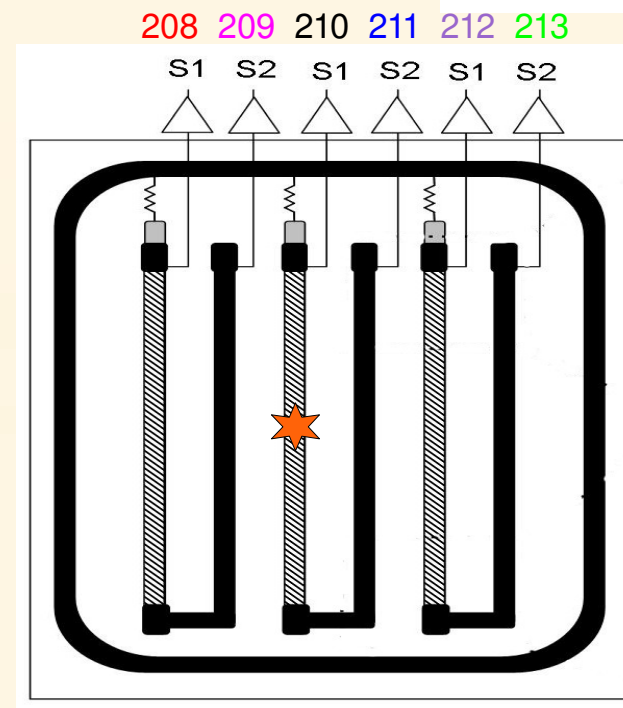
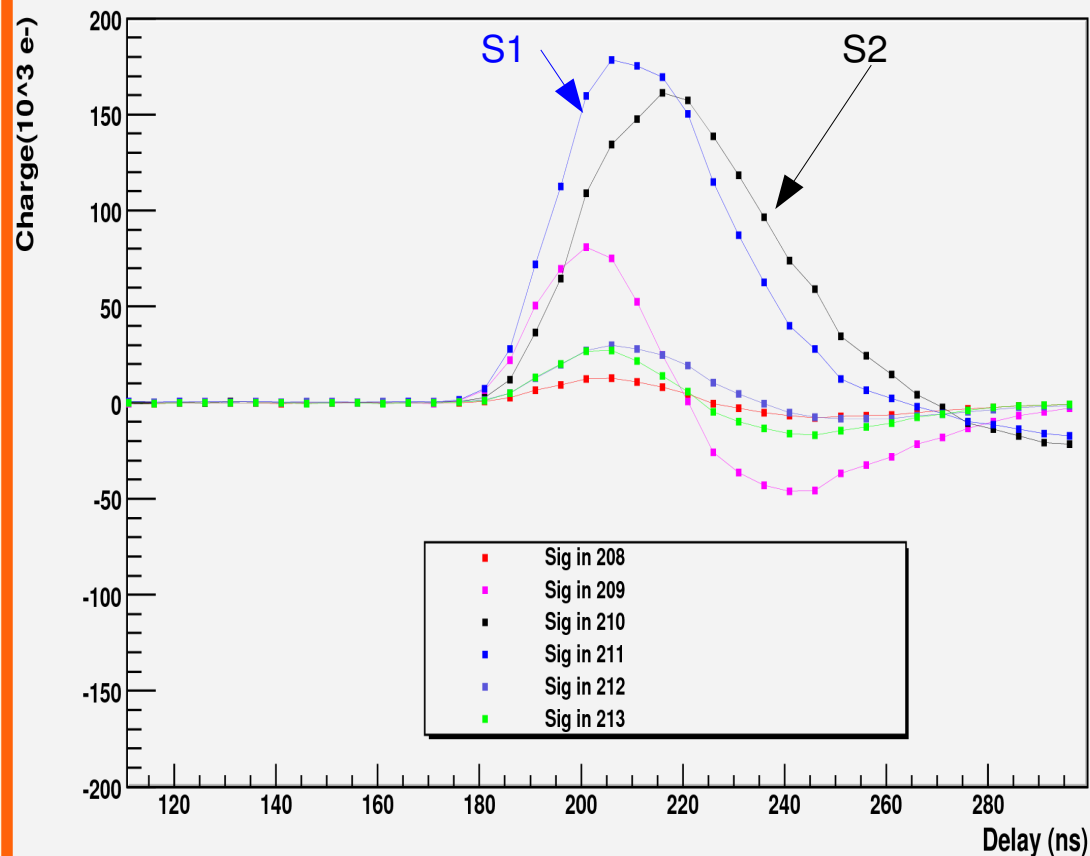
R_{sub} = substrate resistance

C_{sub} = substrate resistance

Unit Cell, a chain of them represents a strip

Laser delay studies

Delay Study laser on Polysilicon strip



Transversal scan

